

Amendments to the Claims:

The following listing of claims will replace all prior versions and listings of claims in the application:

Listing of Claims:

1. (currently amended) A semi-transmitting mirror-possessing substrate assembly comprising:

a glass substrate;

a foundation film directly formed on said glass substrate;

a semi-transmitting reflective film directly formed on said foundation film; and

a liquid crystal layer formed on said semi-transmitting reflective film and interposed between a pair of transparent conductive films,

wherein said foundation film has a thickness in a range of greater than 0 to 8 nm, and

wherein said semi-transmitting reflective film is made of at least one selected from the group consisting of Al and Al alloys.

2. (previously presented) The semi-transmitting mirror-possessing substrate assembly of claim 1, wherein said foundation film is made of silicon oxide (SiO_x).

3. (previously presented) The semi-transmitting mirror-possessing substrate assembly of claim 2, wherein a chemical composition ratio x of oxygen (O) to silicon (Si) in the silicon oxide (SiO_x) is in a range of 1.5 to 2.0.

4. (canceled)

5. (previously presented) A semi-transmitting type liquid crystal display apparatus, comprising a semi-transmitting mirror-possessing substrate assembly as claimed in claim 1.

6. (currently amended) A semi-transmitting mirror-possessing substrate assembly comprising:

a glass substrate;

a foundation film directly formed on said glass substrate, said foundation film being made of silicon oxide (SiO_x) and having a thickness in a range of greater than 0 to 8 nm; [[and]]

a semi-transmitting reflective film directly formed on said foundation film[[.]]; ~~said foundation film being made of silicon oxide (SiO_x) having a thickness in a range of greater than 0 to 8 nm, and~~

a liquid crystal layer formed on said semi-transmitting reflective film and interposed between a pair of transparent conductive films,

wherein a chemical composition ratio x of oxygen (O) to silicon (Si) in the silicon oxide (SiO_x) is in a range of 1.5 to 2.0, and said semi-transmitting reflective film is made of at least one selected from the group consisting of Al and Al alloys.

7. (previously presented) A semi-transmitting type liquid crystal display apparatus, comprising a semi-transmitting mirror-possessing substrate assembly as claimed in claim 6.